

Special Issue

Advances in Metalens: Design and Applications

Message from the Guest Editors

In recent years, metalens technology has attracted much attention from researchers. Devices based on it have been widely designed and applied in various fields, such as optical imaging, optoelectronics, optical communications, and so on. We invite researchers to submit their contributions to this Special Issue, which aims to present original research and review papers that include the design and application of metalens.

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Deadline for manuscript submissions

closed (20 May 2025)



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Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal *Applied Sciences* has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

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